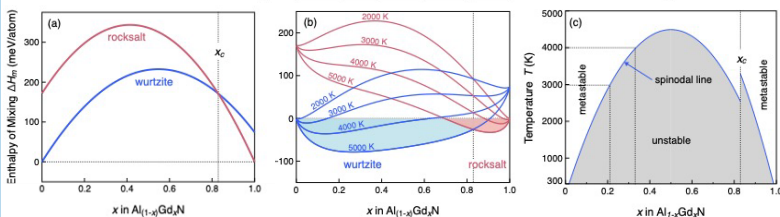


Motivation

Polar wurtzite AlN-based alloy materials have exceptional optoelectronic and charge transport properties (e.g., Al_{1-x}Ga_xN in LEDs and Al_{1-x}Sc_xN as a promising new ferroelectric¹). Other cation substitutions include Ta³⁺, Cr³⁺, Er³⁺, Yb³⁺, and small amounts of Gd³⁺,²⁻⁶ but **ionic size effects** are a serious issue, and **other variables affecting solubility are underexplored** in this family, hampering development of new functional AlN-based alloys.

Thermodynamics of Al_{1-x}Gd_xN

- The ground state is wurtzite up to x_c=0.82, and rocksalt is the ground state for x > x_c
- Calculated T_{eff}-composition phase diagram reveals a large miscibility gap at low T_{eff}
- Higher T_{eff} stabilizes higher Gd³⁺ solubility in wurtzite AlN

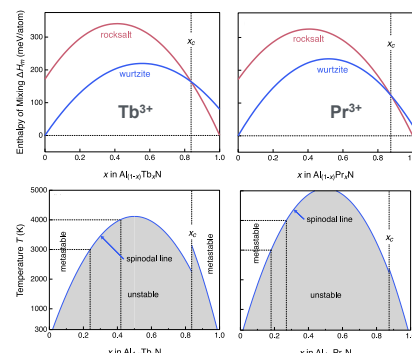


DFT-computed (a) mixing enthalpies, (b) free energies, and (c) T_{eff}-composition phase diagram

Other Al_{1-x}M_xN alloys

Ion	Radius	χ	X_c
Sc ³⁺	0.75 Å	1.36	0.55-0.64 ^{1,3}
Y ³⁺	0.9 Å	1.22	0.75 ³
La ³⁺	1.03 Å	1.1	0.95 ⁷
Pr ³⁺	0.99 Å	1.13	0.87
Gd ³⁺	0.94 Å	1.2	0.82
Tb ³⁺	0.92 Å	1.1	0.84
Yb ³⁺	0.87 Å	1.1	0.75 ⁵
Al ³⁺	0.39 Å	1.61	—

- Trends in x_c due to both **size effects** and **M-N bond ionicity**
- Al-N more polar/covalent
- More ionic M-N bonds allow easier incorporation



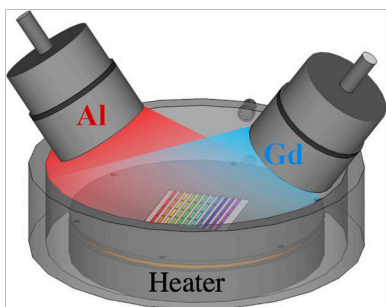
Calculated mixing enthalpies and T_{eff}-composition phase diagrams of Al_{1-x}Tb_xN and Al_{1-x}Pr_xN alloys

Combinatorial thin film growth and structure

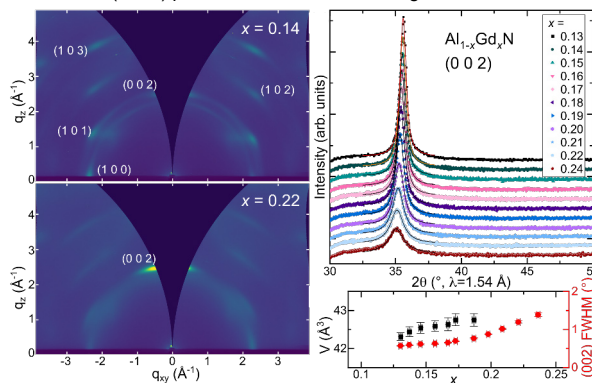
- RF co-sputtering yields a composition gradient roughly Al_{0.87}Gd_{0.13}N – Al_{0.76}Gd_{0.24}N
- Highest previous via sputtering was x≈0.06, with phase separation to Gd above x≈0.1⁶

- GIWAXS (SSRL 11-3) reveals phase-pure wurtzite crystal structure across the composition gradient
- Unit cell volume and c extracted from lab XRD of the (0 0 2) peak are consistent with Vegard's law

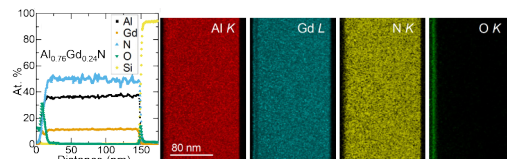
- TEM-EDS shows homogeneous Gd incorporation and negligible oxygen in both x=0.13 and x=0.24
- SAED confirms wurtzite structure
- Semi-oriented sample with columnar grains



Combinatorial RF sputtering setup



GIWAXS patterns and lab XRD at the wurtzite (0 0 2) peak



TEM EDS on Al_{0.76}Gd_{0.24}N and SAED analysis on Al_{0.87}Gd_{0.13}N

Conclusions

- The key to synthesizing Gd-rich wurtzite Al_{1-x}Gd_xN alloys is accessing high T_{eff} (3000–4000 K) under non-equilibrium conditions
- Using RF co-sputtering at T_{eff} ≈ 4000 K, we have experimentally incorporated Gd³⁺ into wurtzite AlN up to x ≈ 0.25
- Universal trends: calculations reveal that bond ionicity is a key determinant of the solubility of large M³⁺ cations in wurtzite AlN